

DRAFT

Appl. No. 10/009,910
Amdt. Dated _____
Reply to Office Action of August 21, 2003

Attorney Docket No. 81839.0107
Customer No.: 26021

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Makoto IIDA et al.

Serial No: 10/009,910

Confirmation No.: 7347

Filed: December 12, 2001

For: SILICON WAFER, SILICON
EPITAXIAL WAFER, ANNEAL
WAFER AND METHOD FOR
PRODUCING THEM

Art Unit: 1765

Examiner: Matthew J. Song

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AMENDMENT

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Alexandria, VA 22313-1450

Dear Sir:

In conjunction with the Request for Continued Examination (RCE) filed on October 8, 2003 in connection with the above-identified application, and pursuant to a phone conference with the Examiner, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 4 of this paper.

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IMPORTANT NOTICE

TELECOPY/FACSIMILE COVER LETTER

TO: Examiner Matthew J. Song
U.S. Patent and Trademark Office
Group Art Unit 1765

DATE: October 14, 2003

FROM: John P. Scherlacher
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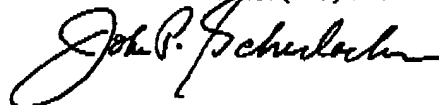
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MESSAGE RE: U.S. Patent Application Serial No. 10/009,910 filed December 12, 2001

Applicant: Makoto IIDA et al; For: SILICON WAFER, SILICON EPITAXIAL WAFER, ANNEAL WAFER AND METHOD FOR PRODUCING THEM

Pursuant to our recent phone conversation, and in connection with an RCE filed October 8, 2003, attached is a proposed Amendment for your consideration. Please review it and call me with your comments

-- John P. Scherlacher, Reg. No. 23,009
Direct Phone No. (213) 337-6846



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TELECOPY/FAX NUMBER: (703) 872-9310

CLIENT NUMBER: 81839.0107

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